

Photoemission

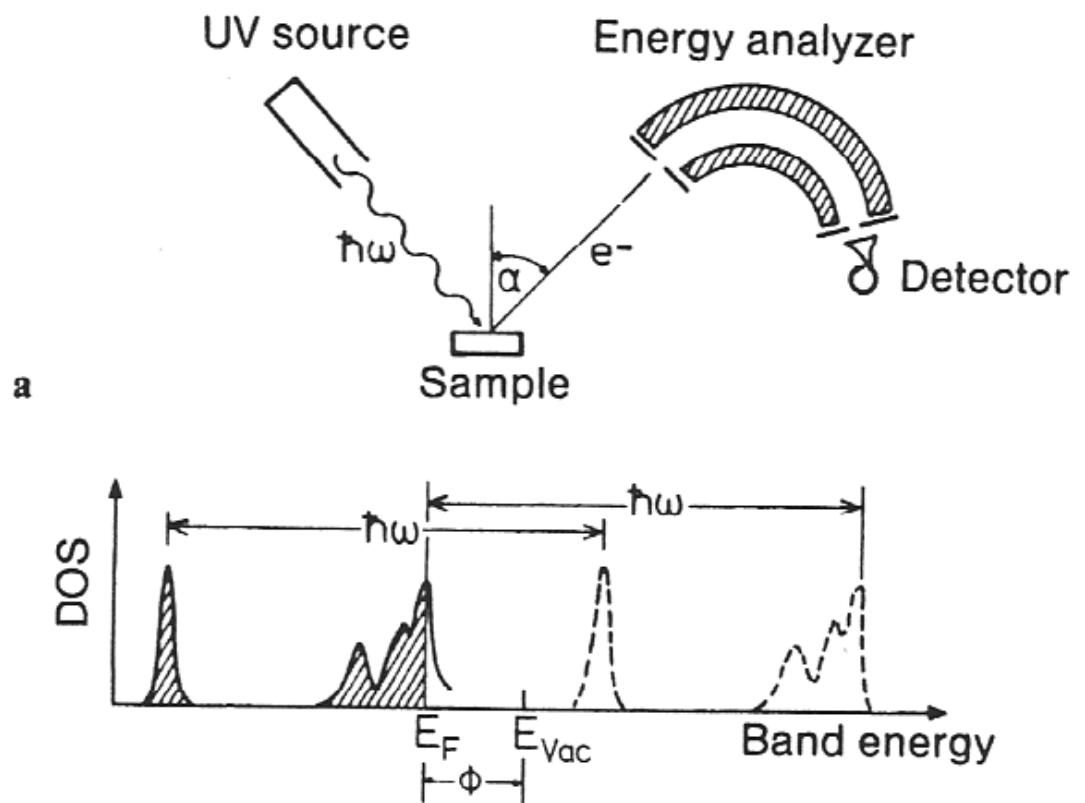
Semiconductors

Photoemission spectroscopy

UPS - Ultraviolet
photoemission spectroscopy

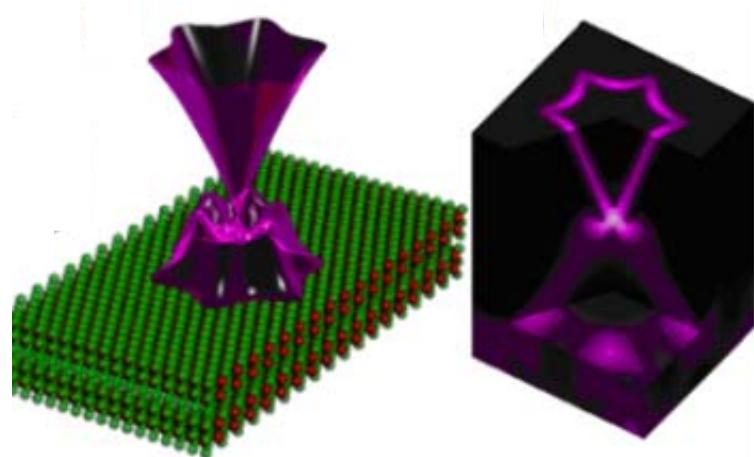
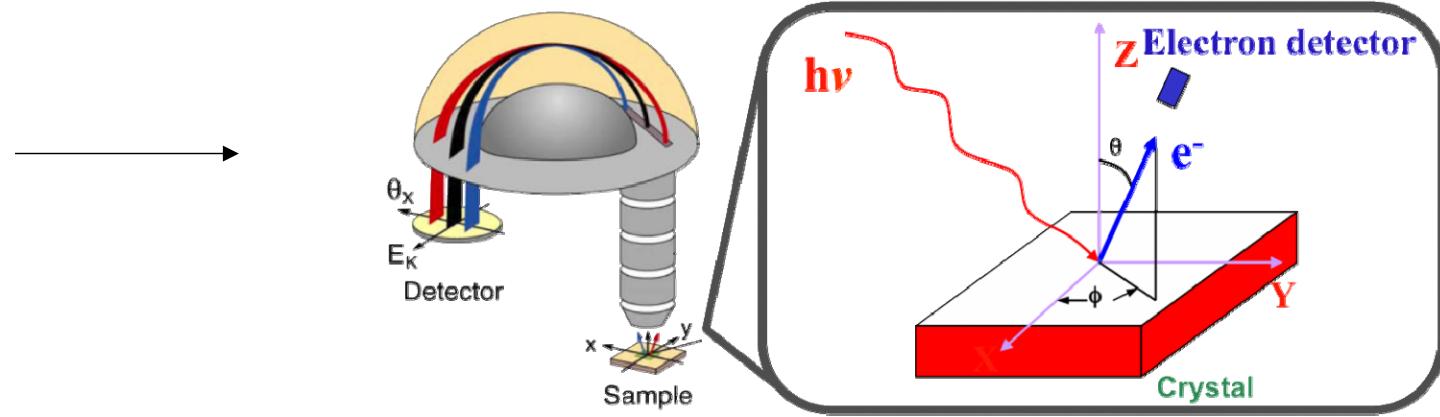
XPS - X-ray photoemission
spectroscopy

Measure the density of states
with photoemission
spectroscopy

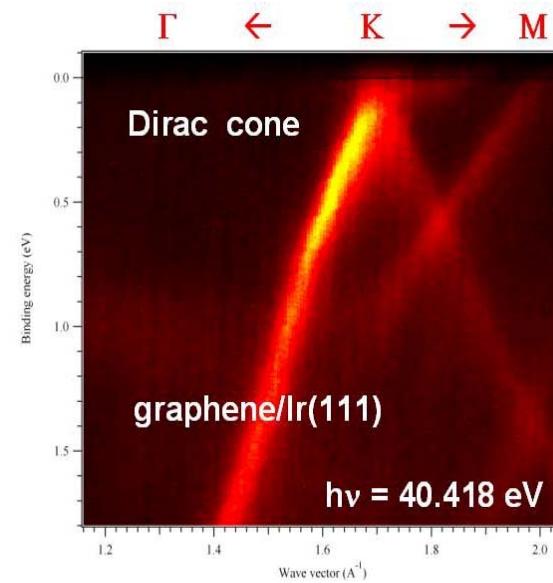


From: Ibach & Lueth

Angle resolved photoemission spectroscopy (ARPES)



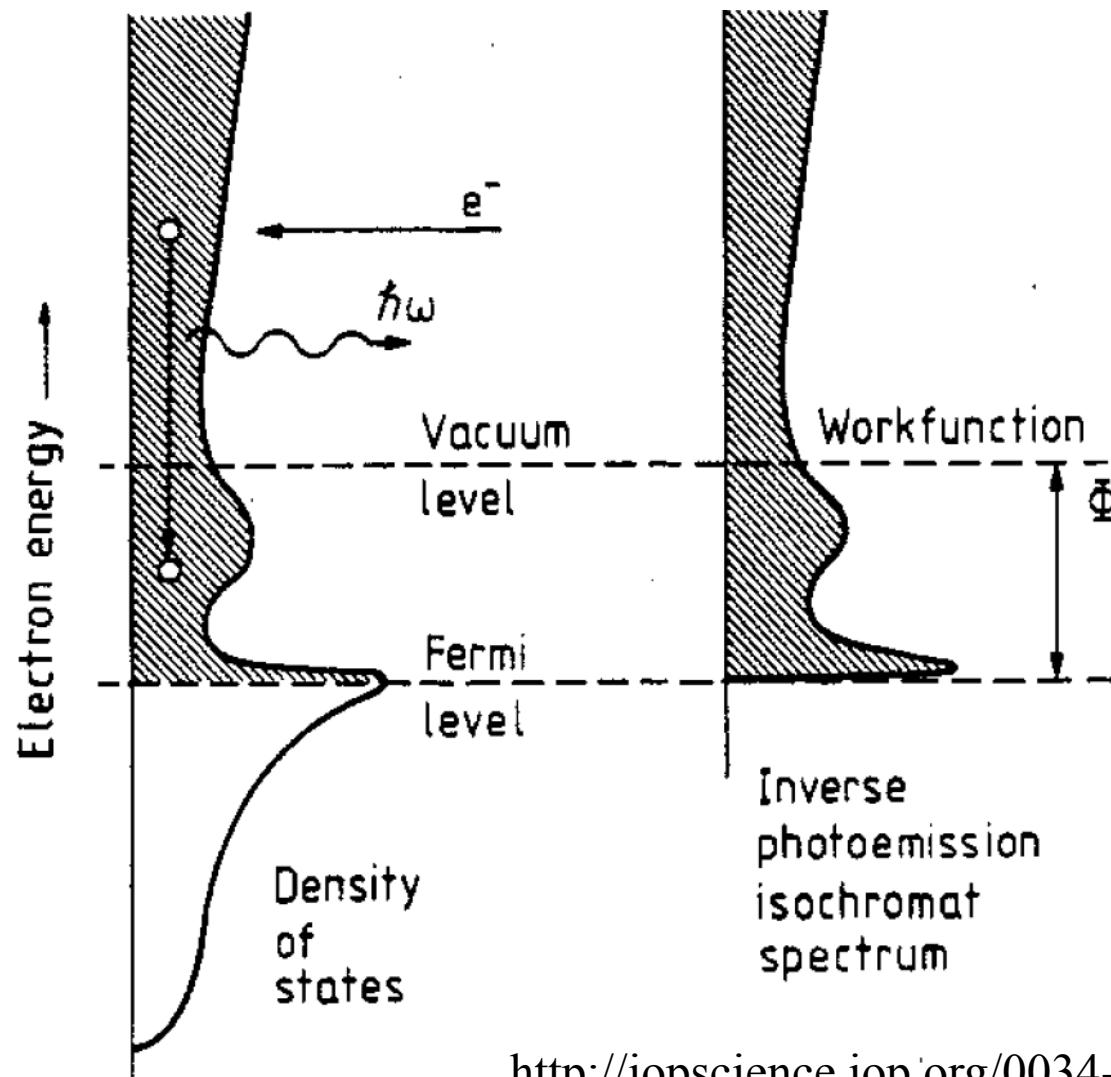
Topological insulator



Measure the dispersion relation with angle resolved photoemission



Inverse photoemission spectroscopy (IPES)



k -resolved Inverse Photoemission Spectroscopy (KRIPIES)

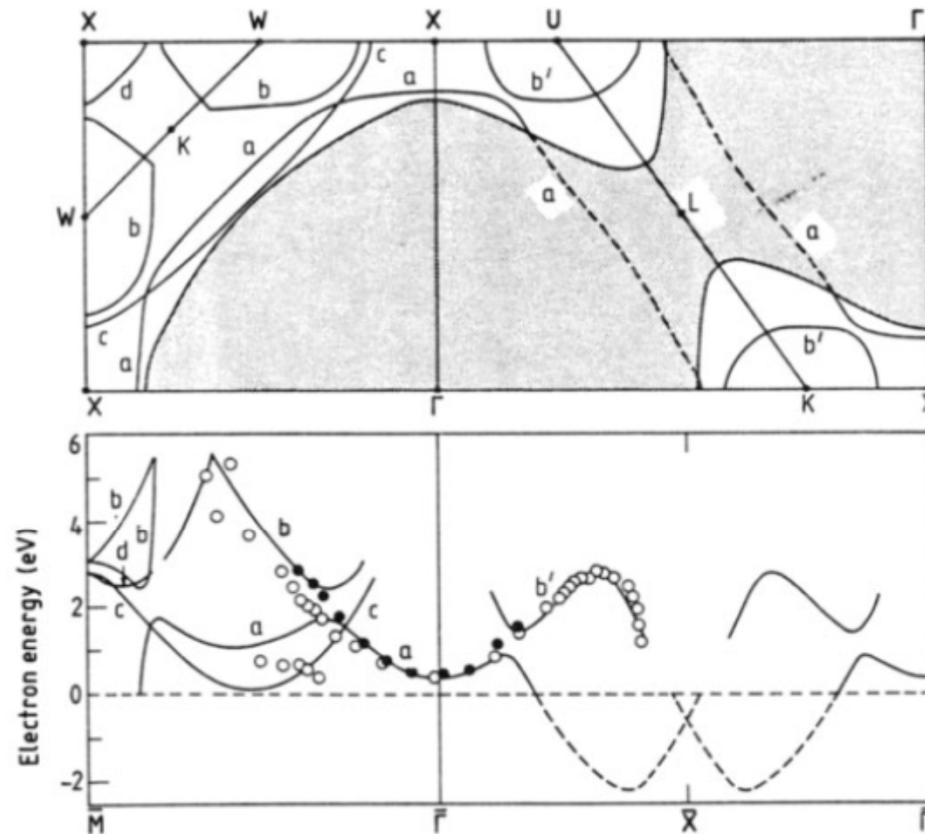
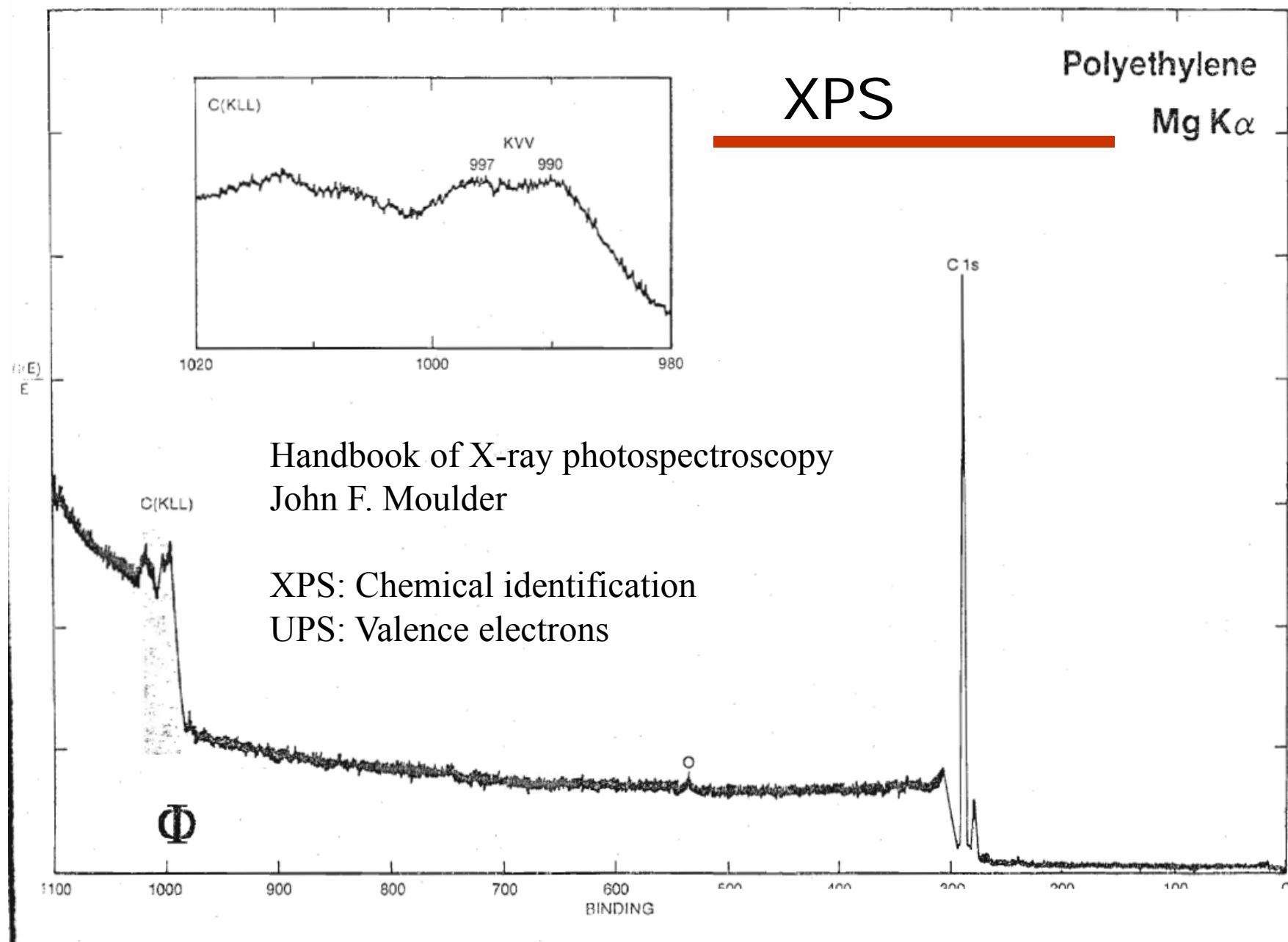


Figure 9. Band calculations and data for bulk direct transitions in the two principal azimuths $\Gamma\bar{M}$ and $\Gamma\bar{X}$ and Cu(001). Upper panel shows the Fermi surface and isochromat curves at $\hbar\omega = 9.7$ eV for transitions into band 6. Lower panel shows the corresponding $E_f(k_{\parallel})$ projections. Computations and filled data circles are from Woodruff *et al* (1982); open circles are data from Jacob *et al* (1986).



Handbook of X-ray photospectroscopy
John F. Moulder

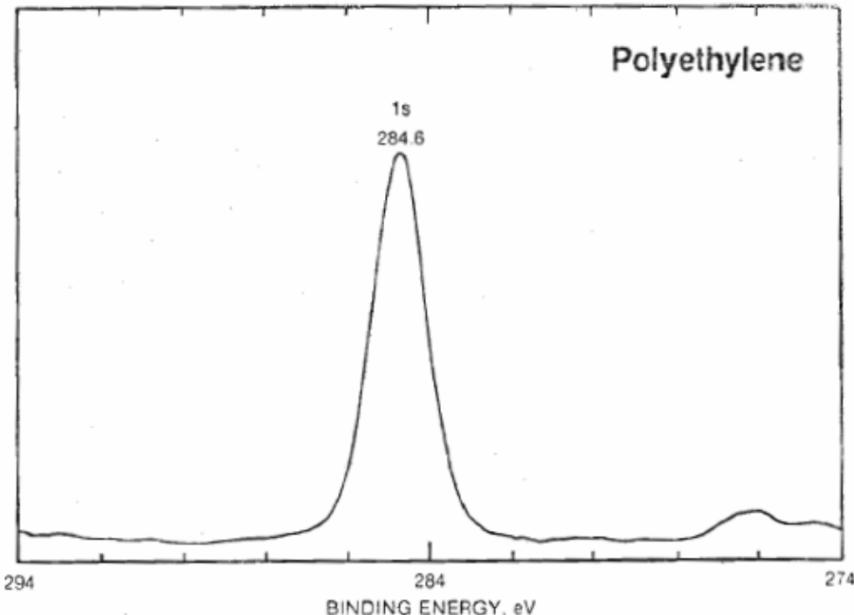
XPS: Chemical identification
UPS: Valence electrons

XPS

Carbon, C Atomic Number 6

HANDBOOK OF X-RAY PHOTOELECTRON SPECTROSCOPY

COMPOUND	1s BINDING ENERGY, eV	REF.
HfC	280	RH1
TiC	284.77	RH1
WC	288	RH1
C (graphite)	292	HJG
(CH ₂) _n	296	Φ
Mn(C ₅ H ₅) ₂		BCD
SnPh ₄		BAL
MeCH ₂ NH ₂		GHH
Cr(C ₆ H ₅) ₂		PFD
MeCH ₂ Cl		GHH
MeCH ₂ OH		GHH
MeCH ₂ OEt		GHH
MeCH ₂ OOCMe		GHH
CS ₂		GHH
Fe(CO) ₅		BC1
Me ₂ CO		GHH
(NH ₂) ₂ CO		GHH
C ₆ F ₆		GHH
MeCOONa		GHH
MeCOOEt		GHH
MeCOOH		GHH
Na ₂ CO ₃		GHH
NaHCO ₃		GHH
CO		BC1
CO ₂		GHH
(CHFCH ₂) _n		CFK
(CHFCHF) _n		CFK
(CHFCF ₂) _n		CFK
(CF ₂ CH ₂) _n		CFK
(CF ₂ CHF) _n		CFK
(CF ₂) _n		CFK
CF ₃ COONa		GHH
CCl ₄		GHH
CF ₃ COMe		GHH
CF ₃ COOEt		GHH



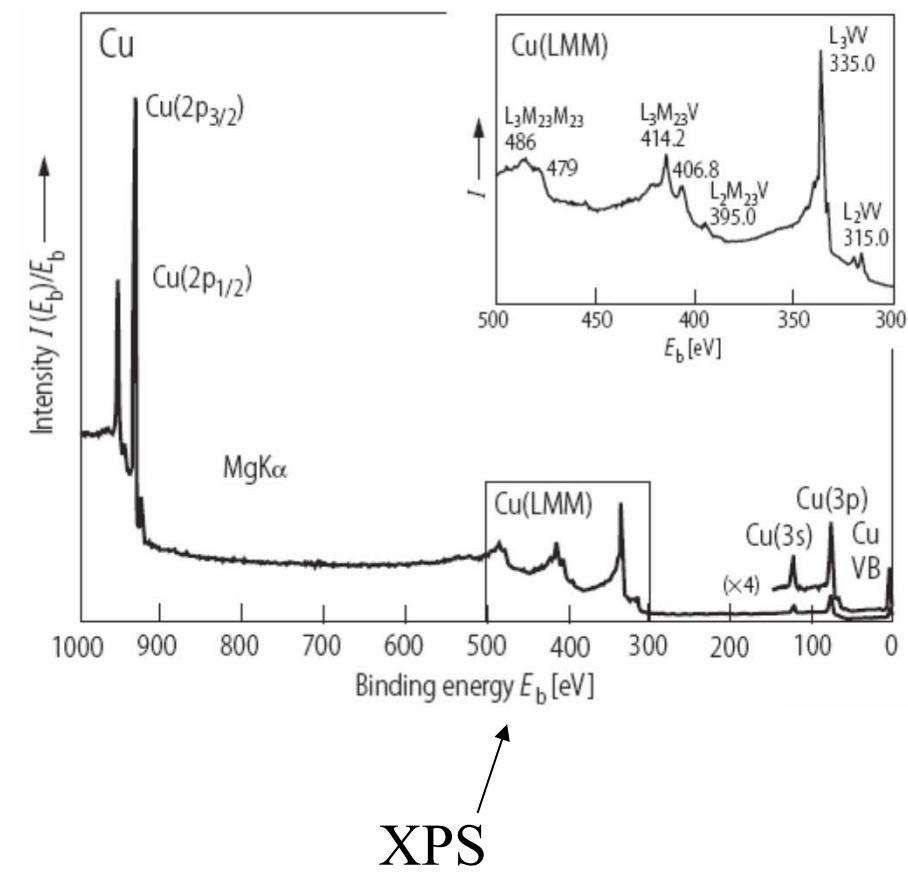
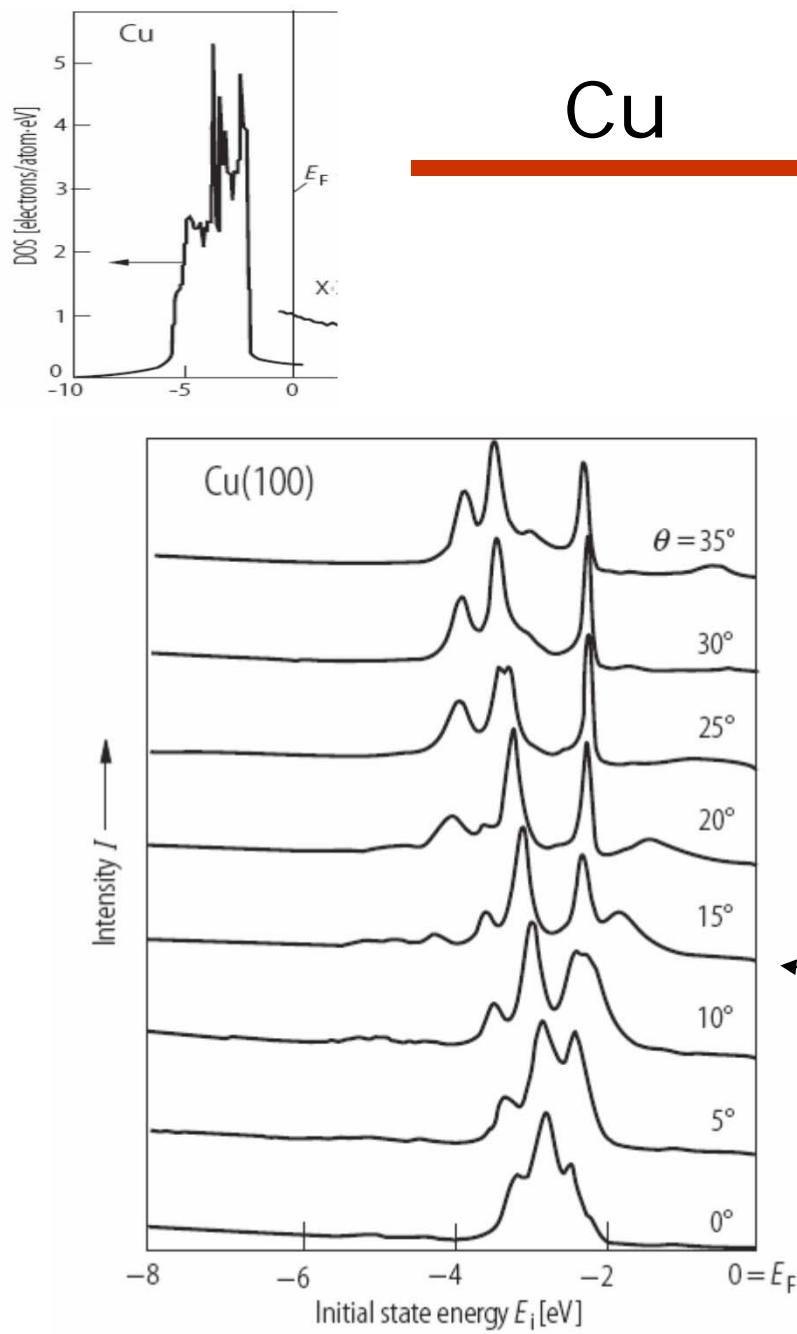
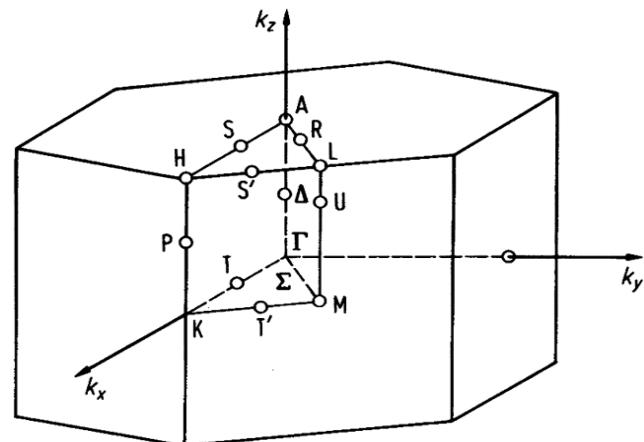
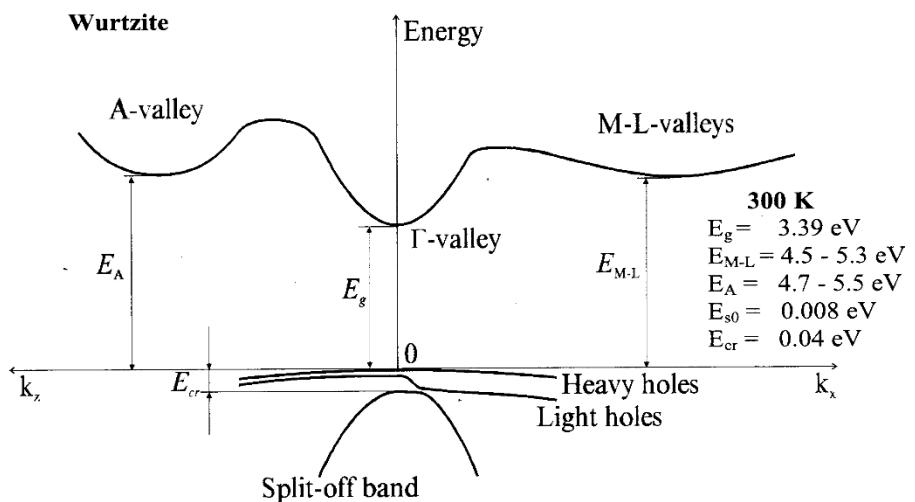
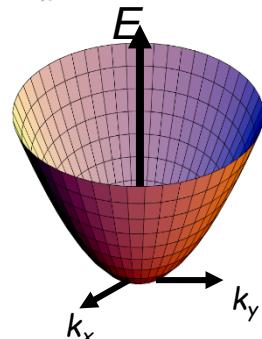
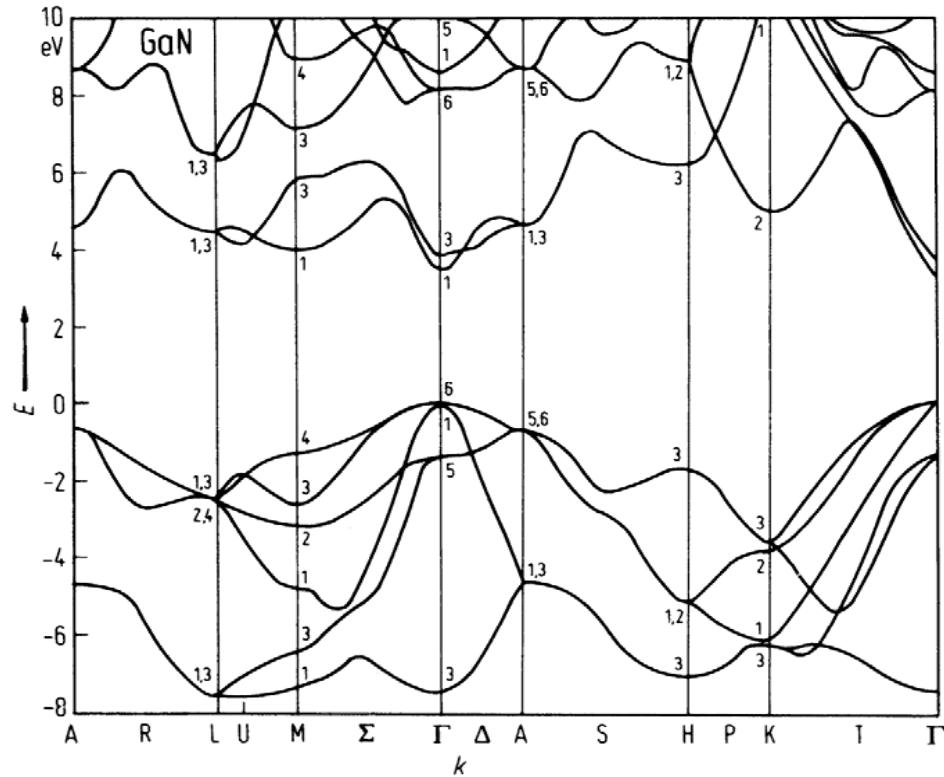


Fig. 28. Cu(100). Angle-resolved photoelectron spectra taken at different polar angles θ along the Γ XUL bulk mirror plane. Photon energy $h\nu = 21.2$ eV, sample temperature $T = 50$ K [93M1]. For further data taken at room temperature see [79H1]. For data taken with linear-polarized photons at $h\nu = 40^\circ$ see [83G].

GaN



1st Brillouin zone of hcp

Free electron Fermi gas

1 - d

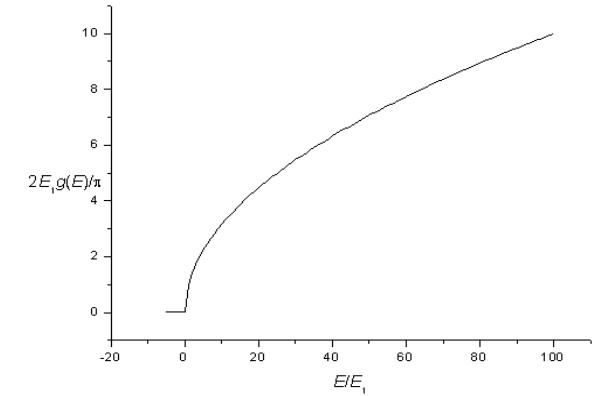
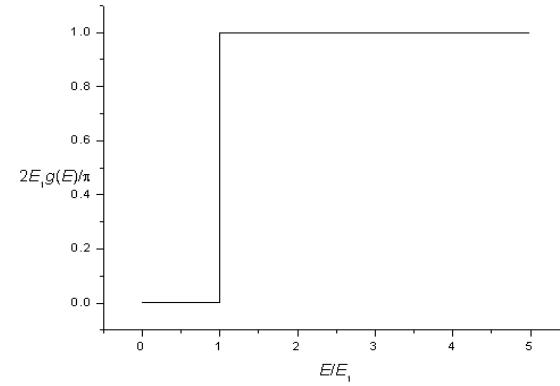
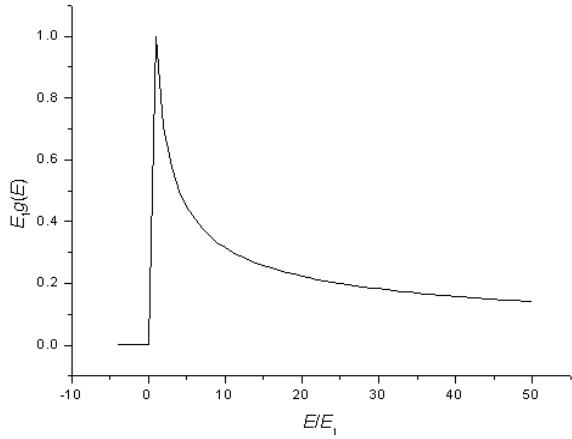
$$D(E) = \sqrt{\frac{2m}{\hbar^2 \pi^2 E}} = \frac{n}{2\sqrt{E_F E}} \quad \text{J}^{-1}\text{m}^{-1}$$

2 - d

$$D(E) = \frac{m}{\hbar^2 \pi} = \frac{n}{E_F} \quad \text{J}^{-1}\text{m}^{-2}$$

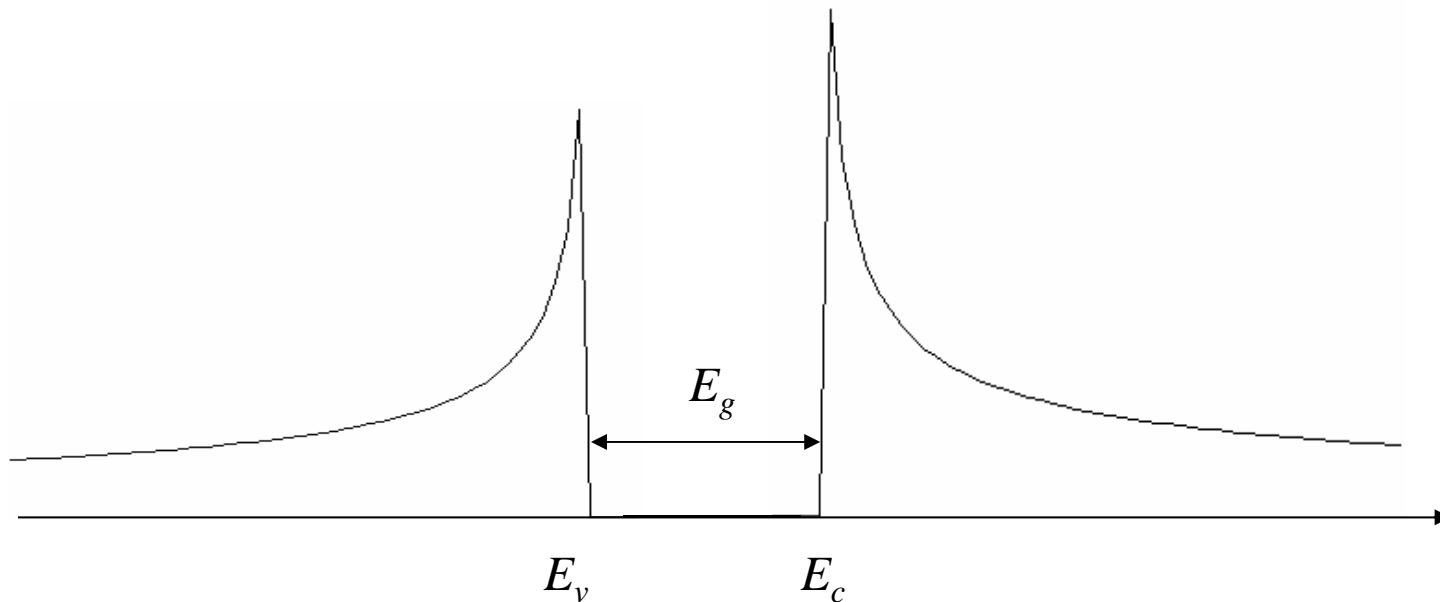
3 - d

$$D(E) = \frac{\pi}{2} \left(\frac{2m}{\hbar^2 \pi^2} \right)^{3/2} \sqrt{E} = \frac{3n}{2E_F^{3/2}} \sqrt{E} \quad \text{J}^{-1}\text{m}^{-3}$$



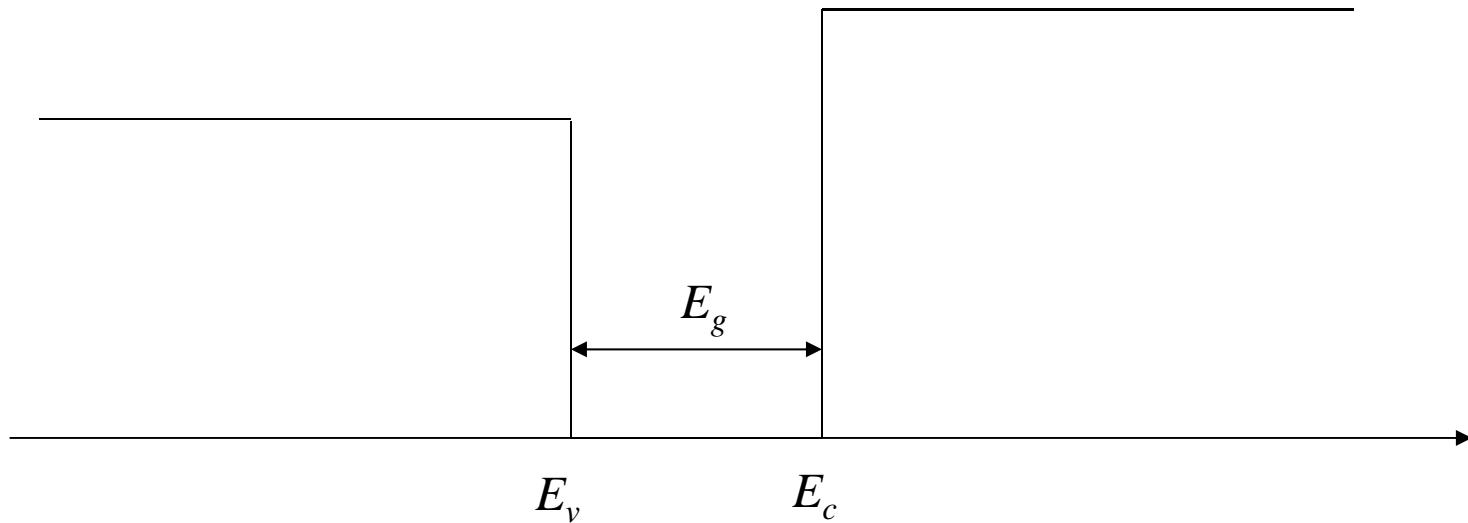
Semiconductors and insulators - 1d

$$E = \frac{\hbar^2(\vec{k} - \vec{k}_0)^2}{2m^*}$$
$$D(E) = \begin{cases} \sqrt{\frac{2m_h^*}{\hbar^2\pi^2(E_v - E)}} & E < E_v \\ 0 & E_v < E < E_c \\ \sqrt{\frac{2m_e^*}{\hbar^2\pi^2(E - E_c)}} & E_c < E \end{cases} \text{ J}^{-1}\text{m}^{-3}$$



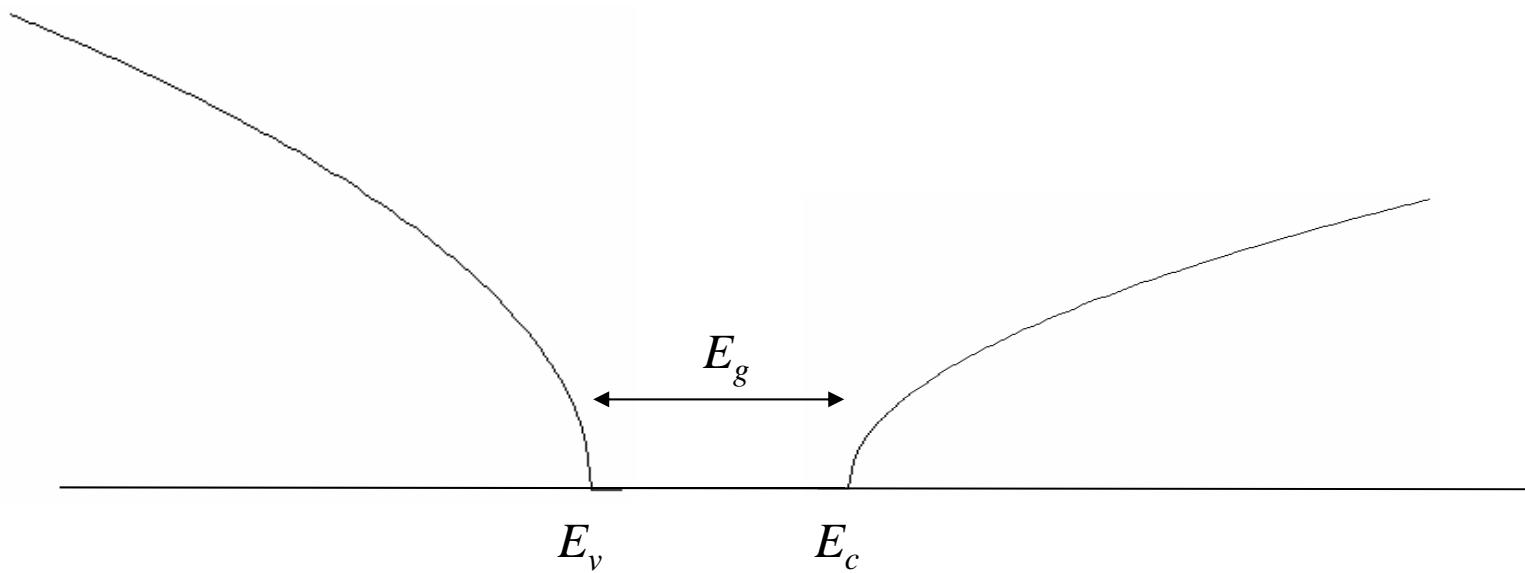
Semiconductors and insulators - 2d

$$D(E) = \begin{cases} \frac{m_h^*}{\hbar^2 \pi} & E < E_v \\ 0 & E_v < E < E_c \quad J^{-1} m^{-3} \\ \frac{m_e^*}{\hbar^2 \pi} & E_c < E \end{cases}$$

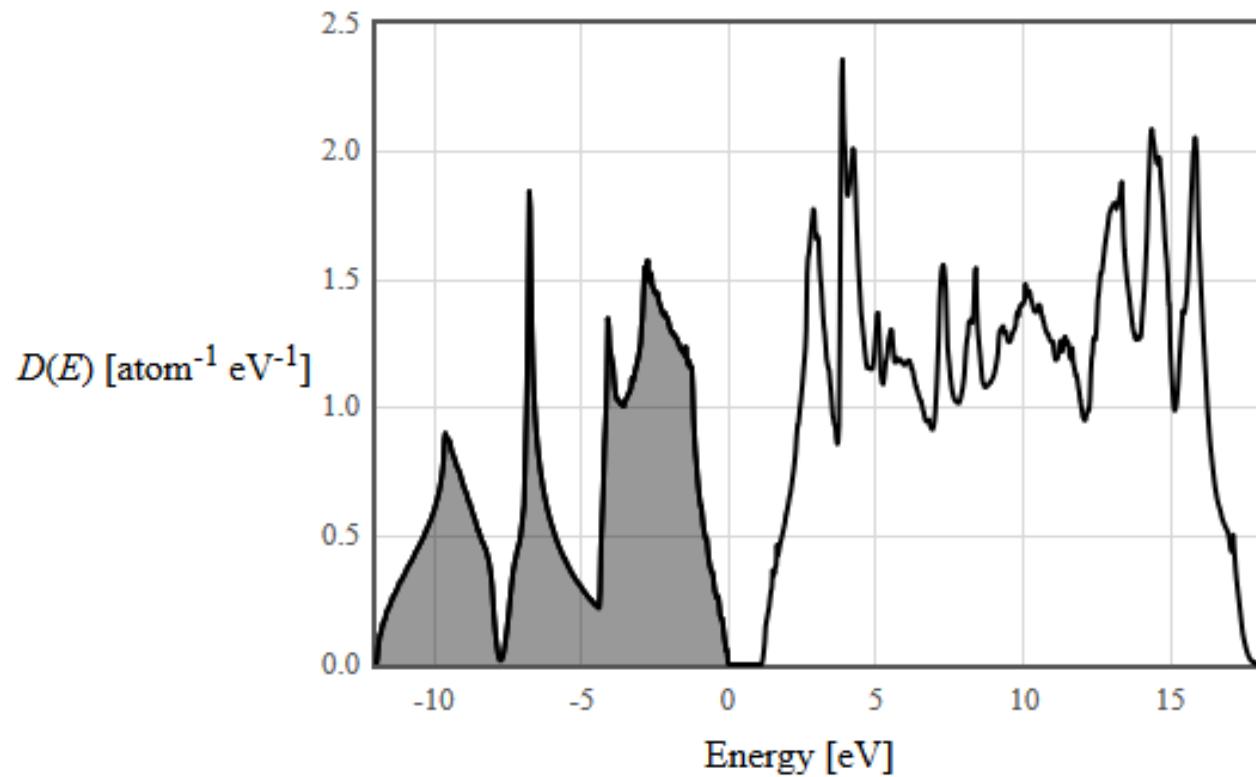


Semiconductors and insulators - 3d

$$D(E) = \begin{cases} \frac{(2m_h^*)^{\frac{3}{2}}}{2\pi^2 \hbar^3} \sqrt{E_v - E} & E < E_v \\ 0 & E_v < E < E_c \\ \frac{(2m_e^*)^{\frac{3}{2}}}{2\pi^2 \hbar^3} \sqrt{E - E_c} & E_c < E \end{cases} \quad \text{J}^{-1} \text{m}^{-3}$$



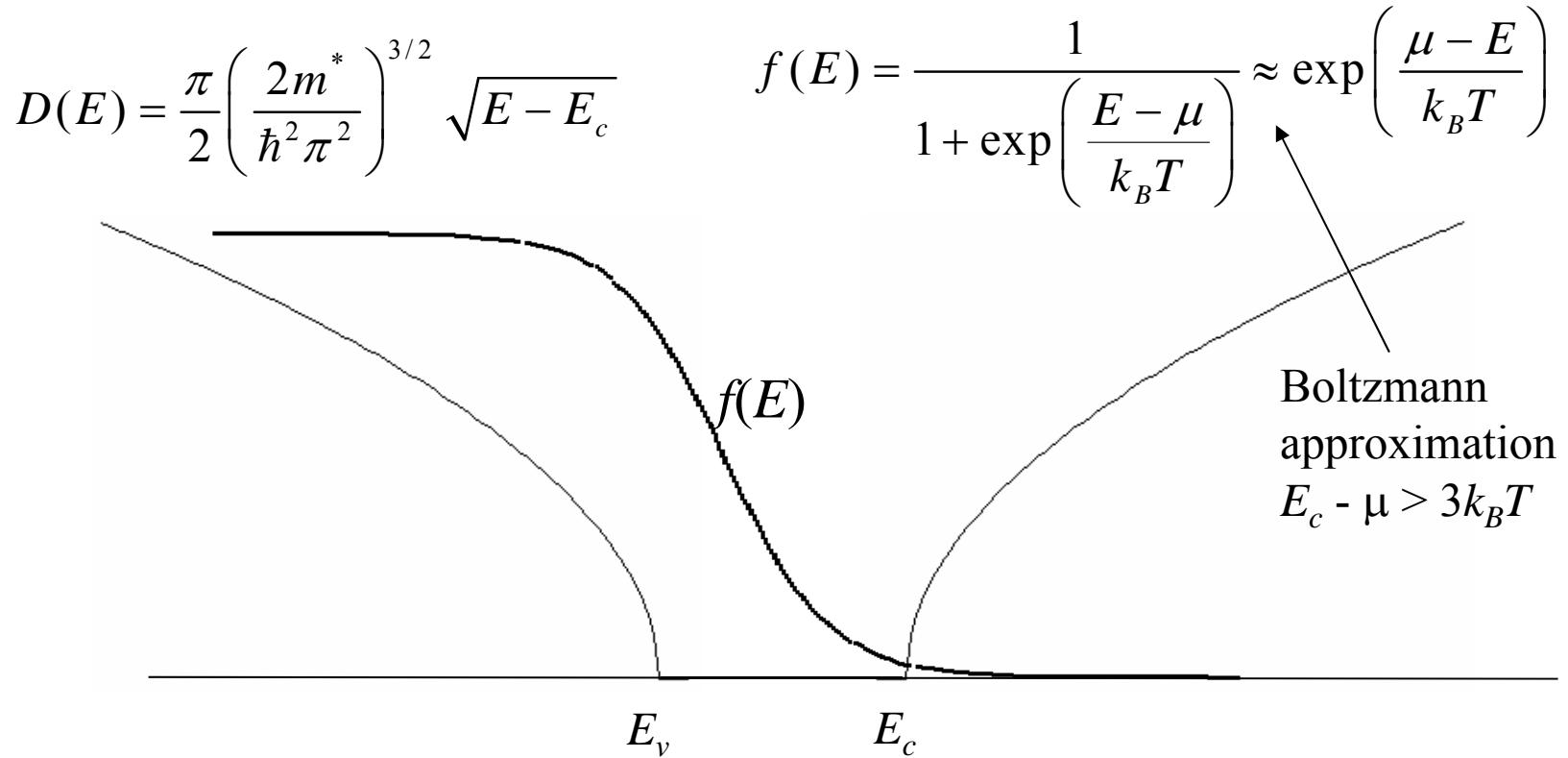
Electron density of states for silicon



E [eV]	$D(E)$ [$\text{eV}^{-1} \text{atom}^{-1}$]	$D(E)$ [$\text{eV}^{-1} \text{m}^{-3}$]	$D(E)$ [$\text{J}^{-1} \text{m}^{-3}$]
-11.965	0	0	0
-11.935	0.02434	1.2155788844464289e+27	7.586935990802827e+45
-11.905	0.06415	3.203754537273558e+27	1.999597139728847e+46
-11.875	0.0932	4.654558423599309e+27	2.9051044960674754e+46
-11.845	0.117	5.843168836492694e+27	3.6469659446340623e+46
-11.815	0.1204	6.012970324048892e+27	3.752946151572146e+46
-11.785	0.1387	6.926901860013134e+27	4.3233690300918325e+46
-11.755	0.1578	7.88078668716707e+27	4.918728427891068e+46

Density of electrons in the conduction band

The free electron density of states is modified by the effective mass.



$$n = \int_{E_c}^{\infty} D(E) f(E) dE \approx \frac{\pi}{2} \left(\frac{2m^*}{\hbar^2 \pi^2} \right)^{3/2} \int_{E_c}^{\infty} \exp\left(\frac{\mu - E}{k_B T}\right) \sqrt{E - E_c} dE$$

Density of electrons in the conduction band

$$n = \int_{E_c}^{\infty} D(E) f(E) dE \approx \frac{\pi}{2} \left(\frac{2m^*}{\hbar^2 \pi^2} \right)^{3/2} \int_{E_c}^{\infty} \exp\left(\frac{\mu - E}{k_B T} \right) \sqrt{E - E_c} dE$$

$$\frac{\sqrt{\pi}}{2} = \int_0^{\infty} \sqrt{x} e^{-x} dx$$

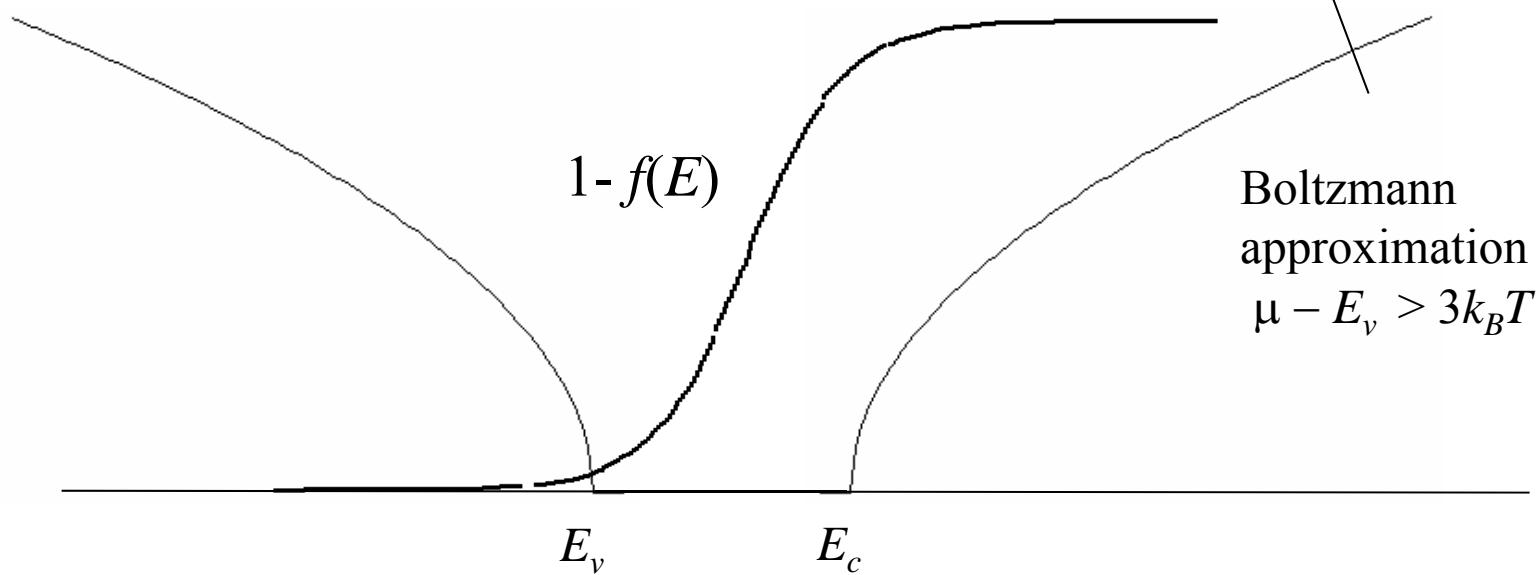
$$n = N_c \exp\left(\frac{\mu - E_c}{k_B T} \right)$$

$$N_c = 2 \left(\frac{m^* k_B T}{2\pi \hbar^2} \right)^{3/2} = \text{effective density of states}$$

Density of holes in the valence band

$$D(E) = \frac{\pi}{2} \left(\frac{2m_h^*}{\hbar^2 \pi^2} \right)^{3/2} \sqrt{E_v - E}$$

$$1 - f(E) = 1 - \frac{1}{1 + \exp\left(\frac{E - \mu}{k_B T}\right)} \approx \exp\left(\frac{E - \mu}{k_B T}\right)$$



$$p = \int_{-\infty}^{E_v} D(E)(1 - f(E)) dE \approx \frac{\pi}{2} \left(\frac{2m_h^*}{\hbar^2 \pi^2} \right)^{3/2} \int_{-\infty}^{E_v} \exp\left(\frac{E - \mu}{k_B T}\right) \sqrt{E_v - E} dE$$

Density of holes in the valence band

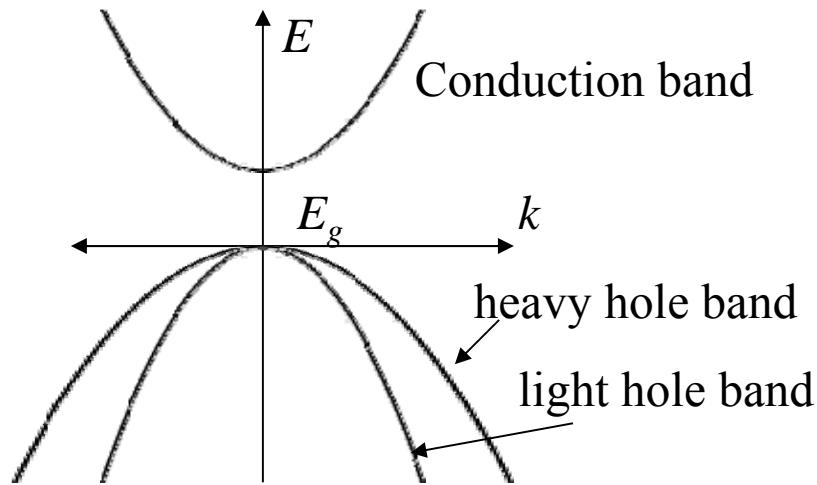
$$p = \frac{1}{L^3} \int_{-\infty}^{E_v} N(E) (1 - f(E)) dE \approx \frac{\pi}{2} \left(\frac{2m_h^*}{\hbar^2 \pi^2} \right)^{3/2} \int_{-\infty}^{E_v} \exp\left(\frac{E - \mu}{k_B T}\right) \sqrt{E_v - E} dE$$

$$p = N_v \exp\left(\frac{E_v - \mu}{k_B T}\right)$$

$$N_v = 2 \left(\frac{m_h^* k_B T}{2\pi \hbar^2} \right)^{3/2}$$

= Effective density of states in
the valence band

Semiconductors



$$n = N_{c300} \left(\frac{T}{300} \right)^{3/2} \exp\left(\frac{\mu - E_c}{k_B T} \right)$$

$$p = N_{v300} \left(\frac{T}{300} \right)^{3/2} \exp\left(\frac{E_v - \mu}{k_B T} \right)$$

Properties	Si	Ge	GaAs
Bandgap E_g	1.12 eV	0.66 eV	1.424 eV
Effective density of states in conduction band (300 K) N_c	$2.78 \times 10^{25} \text{ m}^{-3}$	$1.04 \times 10^{25} \text{ m}^{-3}$	$4.45 \times 10^{23} \text{ m}^{-3}$
Effective density of states in valence band (300 K) N_v	$9.84 \times 10^{24} \text{ m}^{-3}$	$6.0 \times 10^{24} \text{ m}^{-3}$	$7.72 \times 10^{24} \text{ m}^{-3}$
Effective mass electrons m_e^*/m_0	$m_e^* = 0.98$ $m_t^* = 0.19$	$m_l^* = 1.64$ $m_t^* = 0.082$	$m^* = 0.067$
Effective mass holes m_h^*/m_0	$m_{lh}^* = 0.16$ $m_{hh}^* = 0.49$	$m_{lh}^* = 0.044$ $m_{hh}^* = 0.28$	$m_{lh}^* = 0.082$ $m_{hh}^* = 0.45$
Crystal structure	diamond	diamond	zincblende
Density	2.328 g/cm ³	5.3267 g/cm ³	5.32 g/cm ³
Atoms/m ³	5.0×10^{28}	4.42×10^{28}	4.42×10^{28}

The thermodynamic properties of insulators depend on band edges

Boltzmann approximation

The table below gives the contribution of electrons in intrinsic semiconductors and insulators to some thermodynamic quantities. These results were calculated in the Boltzmann approximation where it is assumed that the chemical potential lies in the band gap more than $3k_B T$ from the band edge. The electronic contribution to the thermodynamic quantities are usually much smaller than the contribution of the phonons and thus the electronic components are often simply ignored.

	1-d	2-d
Density of states m_e^* and m_h^* are 'density of states' effective masses	$D(E) = \begin{cases} \frac{1}{\hbar\pi} \sqrt{\frac{2m_h^*}{(E_\nu - E)}} & E < E_\nu \\ 0 & E_\nu < E < E_c \\ \frac{1}{\hbar\pi} \sqrt{\frac{2m_e^*}{(E - E_c)}} & E > E_c \end{cases} \text{ J}^{-1} \text{ m}^{-1}$	$D(E) = \begin{cases} \frac{m_h^*}{\hbar^2\pi} H(E_\nu - E) & E < E_\nu \\ 0 & E_\nu < E < E_c \\ \frac{m_e^*}{\hbar^2\pi} H(E - E_c) & E > E_c \end{cases} \text{ J}^{-1} \text{ m}^{-2}$
Density of states N_ν and N_c are the effective densities of states	$D(E) = \begin{cases} N_\nu(300) \sqrt{\frac{2}{300\pi k_B(E_\nu - E)}} & E < E_\nu \\ 0 & E_\nu < E < E_c \\ N_c(300) \sqrt{\frac{2}{300\pi k_B(E - E_c)}} & E > E_c \end{cases} \text{ J}^{-1} \text{ m}^{-1}$	$D(E) = \begin{cases} \frac{N_\nu(300)}{300k_B} H(E_\nu - E) & E < E_\nu \\ 0 & E_\nu < E < E_c \\ \frac{N_c(300)}{300k_B} H(E - E_c) & E > E_c \end{cases} \text{ J}^{-1} \text{ m}^{-2}$
Density of electrons in the conduction band $n = \int_{E_c}^{\infty} D(E)f(E)dE$	$n = \sqrt{\frac{m_e^* k_B T}{\hbar^2 \pi}} \exp\left(\frac{\mu - E_c}{k_B T}\right) \text{ m}^{-1}$ $= N_c \exp\left(\frac{\mu - E_c}{k_B T}\right)$	$n = \frac{m_e^* k_B T}{\hbar^2 \pi} \exp\left(\frac{\mu - E_c}{k_B T}\right) \text{ m}^{-2}$ $= N_c \exp\left(\frac{\mu - E_c}{k_B T}\right)$
Density of holes in the valence band $p = \int_{-\infty}^{E_v} D(E)(1-f(E))dE$	$p = \sqrt{\frac{m_h^* k_B T}{\hbar^2 \pi}} \exp\left(\frac{E_v - \mu}{k_B T}\right) \text{ m}^{-1}$ $= N_\nu \exp\left(\frac{\mu - E_c}{k_B T}\right)$	$p = \frac{m_h^* k_B T}{\hbar^2 \pi} \exp\left(\frac{E_v - \mu}{k_B T}\right) \text{ m}^{-2}$ $= N_\nu \exp\left(\frac{\mu - E_c}{k_B T}\right)$

$$\tau = \frac{1}{E_v - E_c}$$

$$\tau = \frac{1}{E_v - \mu}$$

Intrinsic semiconductors

In the Boltzmann approximation, the density of states of a semiconductor is,

$$D(E) = \begin{cases} \frac{(2m_h^*)^{3/2}}{2\pi^2\hbar^3} \sqrt{E_v - E}, & \text{for } E < E_v \\ 0, & \text{for } E_v < E < E_c \\ \frac{(2m_e^*)^{3/2}}{2\pi^2\hbar^3} \sqrt{E - E_c}, & \text{for } E_c < E \end{cases}$$

Here m_e^* and m_h^* are the 'density of states effective masses' for electrons and holes. Usually in the literature, effective density of states at 300 K is given instead of the 'density of states effective masses'. The relationship between the two is,

$$\begin{aligned} m_h^* &= \frac{\pi\hbar^2}{300k_B} \left(\sqrt{2}N_v(300) \right)^{2/3} \\ m_e^* &= \frac{\pi\hbar^2}{300k_B} \left(\sqrt{2}N_c(300) \right)^{2/3} \end{aligned}$$

The density of states can therefore also be written as,

$$D(E) = \begin{cases} \frac{2N_v(300)}{\sqrt{\pi}} \left(\frac{1}{300k_B} \right)^{3/2} \sqrt{E_v - E}, & \text{for } E < E_v \\ 0, & \text{for } E_v < E < E_c \\ \frac{2N_c(300)}{\sqrt{\pi}} \left(\frac{1}{300k_B} \right)^{3/2} \sqrt{E - E_c}, & \text{for } E_c < E \end{cases}$$

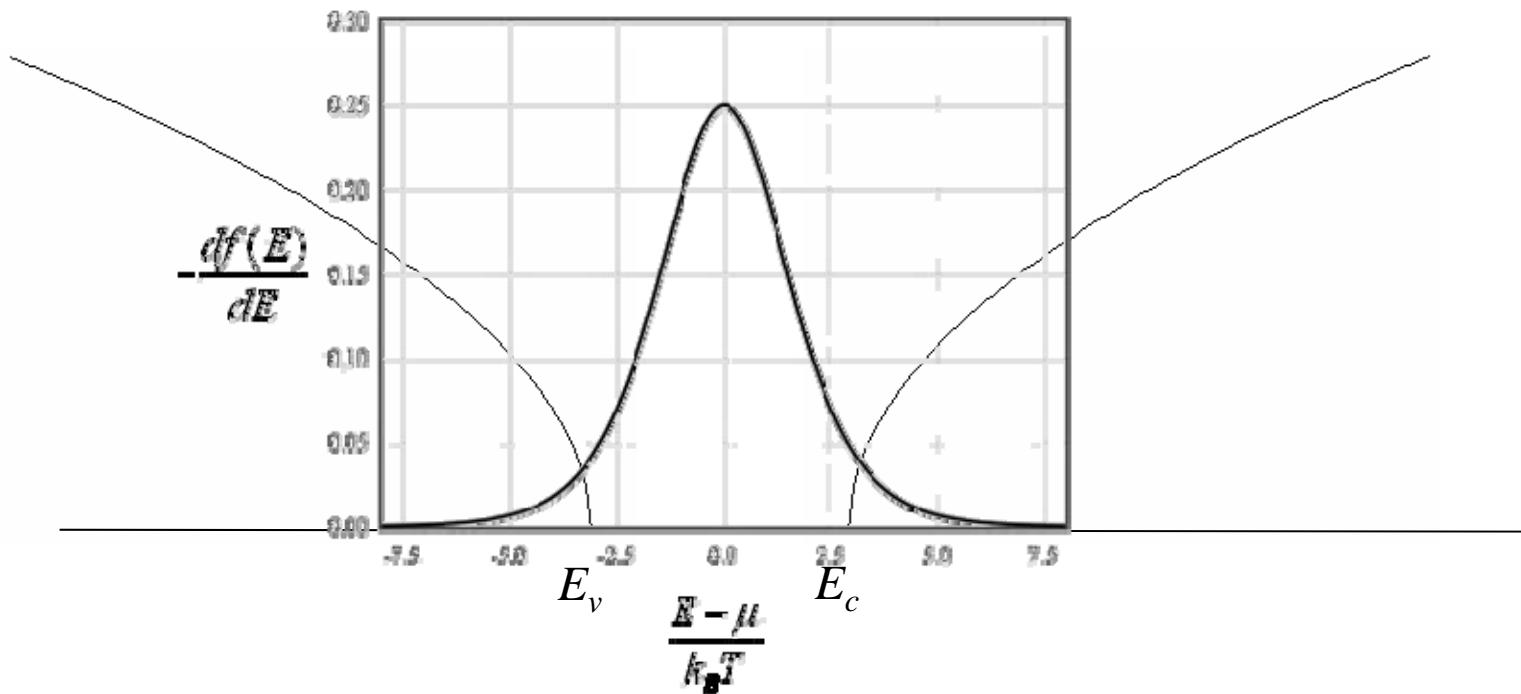
In an intrinsic semiconductor, the density of electrons equals the density of holes. The intrinsic carrier concentration, n_i , depends exponentially on the bandgap, E_g . For most semiconductors the bandgap is a function of temperature. The plots on this page use the temperature dependence specified in the form below.

$$n = p = n_i = \sqrt{N_c \left(\frac{T}{300} \right)^{3/2} N_v \left(\frac{T}{300} \right)^{3/2}} \exp \left(\frac{-E_g}{2k_B T} \right).$$

By setting the concentration of electrons equal to the concentration of holes, it is possible to solve for the chemical potential.

$$\begin{aligned} n = N_c(300) \left(\frac{T}{300} \right)^{3/2} \exp \left(\frac{\mu - E_c}{k_B T} \right) &= p = N_v(300) \left(\frac{T}{300} \right)^{3/2} \exp \left(\frac{E_v - \mu}{k_B T} \right). \\ \mu &= \frac{E_v + E_c}{2} + k_B T \ln \left(\frac{N_v(300)}{N_c(300)} \right). \end{aligned}$$

Narrow bandgap semiconductors



Use the programs for metals for small bandgap semiconductors.